ÆILE 'HOME' ENTERED AT 09:32:16 ON 21 JUL 2005)

```
FILE 'INSPEC' ENTERED AT 09:32:38 ON 21 JUL 2005
Ľĺ
            143 PERIPHER#### CIRCUIT
L2
        170858 BOND#######
         47186 POROUS
L3
         52766 (SWITCH##### OR DISPLAY)(P) CIRCUIT
L4
L5
             0 L1 AND L2 AND L3 AND L4
          36066 PERIP######
L6
L7
              O L6 AND L2 AND L3 AND L4
             0 L2 AND L3 AND L4
L8
L9
             23 L1 AND L4
             0 L2 AND L9
L10
     FILE 'CA' ENTERED AT 09:36:11 ON 21 JUL 2005
L11
             0 L5
             36 L9
L12
L13
             0 L3 AND L12
           4 L12 AND L2
L14
```

```
R 1 OF 4 CA COPYRIGHT 2005 ACS on STN
   142:269388 CA
AN
    Entered STN: 24 Mar 2005
ED
ΤT
    Method for manufacturing liquid crystal display
    Lee, Seong Hak
IN
PΑ
    LG Philips LCD Co., Ltd., S. Korea
    Repub. Korean Kongkae Taeho Kongbo, No pp. given
SO
    CODEN: KRXXA7
DT
    Patent
LA
    Korean
IC
    ICM G02F001-1337
CC
    74-13 (Radiation Chemistry, Photochemistry, and Photographic and Other
    Reprographic Processes)
FAN.CNT 1
                      KIND DATE
                                       APPLICATION NO. DATE
    PATENT NO.
    _____
                      ____
                             -----
                                        ______
    KR 2003094529
PΙ
                      A
                             20031218 KR 2002-31227 20020604
PRAI KR 2002-31227
                             20020604
CLASS
PATENT NO. CLASS PATENT FAMILY CLASSIFICATION CODES
KR 2003094529 ICM G02F001-1337
AB A method for manufacturing a liquid crystal display is provided to
    reduce static electricity generated in a rubbing process, thereby
    preventing peripheral circuit part from being short.
    Alignment films are applied on active areas of an upper substrate and a
    lower substrate. Masks are placed on the upper substrate and the lower
    substrate, having the active areas as aperture parts. The aperture parts
    of the masks are rubbed. A seal pattern with an injection port is formed
    on the lower substrate. A plurality of spacers are scattered on the lower
    substrate. The upper substrate and the lower substrate are bonded
    with each other. The bonded upper substrate and the lower
     substrate are cut. Liquid crystal is injected between the upper substrate
     and the lower substrate through the injection port.
ST
    liq crystal display manuf alignment film rubbing process
ΙT
    Liquid crystal displays
        (method for manufacturing liquid crystal display)
    ANSWER 2 OF 4 CA COPYRIGHT 2005 ACS on STN
L14
    141:251544 CA
AN
    Entered STN: 30 Sep 2004
ED
    High resolution and brightness full-color led display manufactured using
ΤI
     chemical-mechanical polishing technique
     Dai, Yuan-Tung; Peng, Yuan-Ching; Chen, Chien-Chih
ΙN
     Industrial Technology Research Institute, Taiwan
PΑ
     Taiwan., 7 pp.
    CODEN: TWXXA5
DT
    Patent
LA
    Chinese
IC
     ICM H01L033-00
     74-13 (Radiation Chemistry, Photochemistry, and Photographic and Other
     Reprographic Processes)
     Section cross-reference(s): 73, 76
FAN.CNT 1
                                   APPLICATION NO.
     PATENT NO.
                       KIND
                              DATE
                                         _____.
     ______
                       ____
                              _____
    TW 486830
                       В
                              20020511
                                       TW 2001-90102754
                                                              20010208
PRAI TW 2001-90102754
                              20010208
 PATENT NO. CLASS PATENT FAMILY CLASSIFICATION CODES
 _____
 TW 486830 ICM H01L033-00
   A full-color LED display consists of red, green, and blue LED
    elements. Red and green LED elements are formed on a first substrate and
```

covered by a first buffer layer. A second substrate is bonded. to the buffer layer and polished to a thin substrate layer on which a blue LED element is formed. Then, a second buffer layer covers all three LED elements to form a full-color LED device. By arranging multiple full-color LED devices in rows and columns, and addressing and controlling each LED device by suitable wires, electrode layer and peripheral circuit, it is able to form a full-color LED display with high resolution and brightness. full color electroluminescent display fabrication; polishing chem mech fabrication electroluminescent display Polishing (chemical-mech.; high resolution and brightness full-color LED display manufactured using chemical-mech. polishing technique) Electroluminescent devices Semiconductor device fabrication Semiconductor electroluminescent devices (high resolution and brightness full-color LED display manufactured using chemical-mech. polishing technique) L14 ANSWER 3 OF 4 CA COPYRIGHT 2005 ACS on STN 132:116202 CA Entered STN: 18 Feb 2000 Manufacture of semiconductor memory devices Inoue, Yoshihiko; Yoshioka, Hiroshi; Ureshino, Kazuhisa; Ohara, Kazuaki; Mishima, Michihiro Hitachi, Ltd., Japan; Hitachi Super LSI System Co., Ltd.; Renesas Technology Corp. Jpn. Kokai Tokkyo Koho, 12 pp. CODEN: JKXXAF Patent Japanese ICM H01L027-108 ICS H01L021-8242; H01L021-3205; H01L021-8234; H01L027-088; H01L027-10 76-3 (Electric Phenomena) FAN.CNT 1 APPLICATION NO. DATE PATENT NO. KIND DATE -----______ JP 1998-200276 JP 2000031415 A2 20000128 19980715 В2 JP 3583927 20041104 PRAI JP 1998-200276 19980715 CLASS PATENT NO. CLASS PATENT FAMILY CLASSIFICATION CODES ICM H01L027-108 JP 2000031415 H01L021-8242; H01L021-3205; H01L021-8234; H01L027-088; H01L027-10 Adjusting input/output capacitance value of the semiconductor device, to maximum and lowest standard or the request of the customer, adjust. Functions the principal plane of semiconductor substrate as the component separation territory the formation to do thick silicone oxide film, 1st electrode the formation is done on silicone oxide film of the peripheral circuit territory. 1st electrode is formed simultaneously with the gate electrode of the MISFETs for memory cell selection. 1St and 2nd $\,$ electrodes, which are actually semiconductor substrates, constitute, along with Si oxide insulator films, parallel-plate-type capacitors. The 1st electrode is connected to the bonding pad of 3rd interconnection layer. Selection of connection to bonding pads is carried out by the modification of the patterns of metal switching parts. semiconductor memory device MIS FET Electric capacitance Semiconductor device fabrication Semiconductor memory devices

(adjustment of input/output capacitance in manufacture of semiconductor

ST

ΙT

ΙT

ΑN ED

TI

IN

PΑ

SO

DT

LA

IC

CC

AB

in

ST

ΙT

```
memory devices)
IT
    MISFET (transistors)
       (manufacture of semiconductor memory devices)
IT
    7631-86-9, Silica, uses
    RL: DEV (Device component use); USES (Uses).
       (adjustment of input/output capacitance in manufacture of semiconductor
       memory devices)
    ANSWER 4 OF 4 CA COPYRIGHT 2005 ACS on STN
L14
    127:286007 CA
AN
ED
    Entered STN: 11 Nov 1997
    Active matrix type liquid crystal display device and its manufacture
TΙ
IN
    Inoue, Shunsuke; Okita, Akira
PΑ
    Canon K. K., Japan
    Jpn. Kokai Tokkyo Koho, 6 pp.
SO
    CODEN: JKXXAF
DT
    Patent
ĹΑ
    Japanese
    ICM G02F001-1343
IC
    ICS G02F001-136
CC
    74-13 (Radiation Chemistry, Photochemistry, and Photographic and Other
    Reprographic Processes)
FAN.CNT 1
    PATENT NO.
                      KIND
                              DATE APPLICATION NO.
                                                              DATE
                      ----
    _____
                              -----
                                         ______
    JP 09244045
                        A2
                                       JP 1996-56063
                              19970919
                                                               19960313
PΤ
PRAI JP 1996-56063
                              19960313
CLASS
            `CLASS PATENT FAMILY CLASSIFICATION CODES
 PATENT NO.
 ______
 JP 09244045
              ICM G02F001-1343
               ICS
                      G02F001-136
AB
    In the liquid-crystal display device comprising a liquid-crystal
    layer enclosed between a substrate equipped with image display
    units containing a switching element and peripheral circuits for
    sending signals to the display units, and another substrate
    bearing a transparent electrode, an electrode layer of the type used for
    the pixel electrode in each display unit is also formed on the
    bonding pad of the peripheral circuit. Also
    claimed is a method for manufacturing the above liquid-crystal display
    device. The properties of the switching elements are improved.
    active matrix liq crystal display; bonding pad liq crystal
ST
    display
    Liquid crystal displays
IT
        (active matrix type liquid crystal display device and its manufacture)
```

WEST Search History

Hide Items Restore Clear Cancel

DATE: Thursday, July 21, 2005

Hide?	Set Name	- ·	Hit Count
1	<i>DB=PG</i> L59	PB, USPT, EPAB, JPAB, DWPI, TDBD; PLUR = 1 L58 and 141	(ES; OP = OR)
	L58	L57 and 156 and 151	54
· <u>'</u> _	L57	switch\$5 or display\$5	4079269
	L56	switch\$5 or display\$5	4079269
	L55	perpher\$5	1294
	L54	perpher\$5 .	1294
	L53	151 and 141	0
	L52	L51 and 144	. 0
<u>'</u> _	L51	L50 and 145	54
	L50	L49 and 148	5.4
	L49	tatsuya.inv.	47981
	L48	L47 and tft and l45	68
	L47	active adj matrix	41021
	L46	thin adj film	438646
	L45	shimoda.inv.	9524
	L44	bond\$5 and 142	15
	L43	15 and 142	1
	L42	L41 and 140	30
	L41	porous	432210
	L40	mulpuri.xa,xp.	598
	L39	135 and 137	27
	L38	L37 and 14	Q
	L37	hideo.asn.	3804
	L36	L35 and 14	7
. П	L35	sony.asn.	285376
	L34	l33 not l24	49
	L33	132 not 130	56
	L32	L31 and 15	66
	L31	438/10-127.ccls.	34345
	L30	L29 and 15	44
	L29	438/455-465.ccls.	4843

	L28	438/455465.ccls.	0
	L27	123 not 125	5
	L26	124 not 123	135
\Box	L25	L24 and l23	19
	L24	leedy.inv.	154
	L23	112 and 119	24
	L22	L21 and l4	1254
	L21	mono and poly\$5	185478
70.00	L20	L19 and l15 and l16	2
	L19	L18 and l17	693
	L18	polycrystal\$5	107174
	L17	(mono adj crystal\$5) or mono-crystal\$5	3232
<u> </u>	L16	display adj circuit	16158
	L15	peripher\$5 adj circuit	28031
	L14	peripher45 adj circuit	0
	L13	L12 and 19	187
	L12	L11 and 15	557
	L11	257/\$.ccls.	312967
	L10	257/\$.ccls.	312967
	L9	L8 and 15	260
	L8	438/\$.ccls.	169737
	L7	L6 and 15	129
	L6	349/\$.ccls.	36771
	L5	peripher\$5 and bond\$5 and porous and display	5813
	L4	peripher\$5 and bond\$5 and porous and display	5813
	L3	perpher\$5 and bond\$5 and porous and display	3
	L2	porous and bond\$5 and perpher\$5 and display	3
	L1	display and porus and bond\$5 and peripher\$5	7

END OF SEARCH HISTORY